

Electronic Patent Application Fee Transmittal

Application Number:	10591718			
Filing Date:	05-Sep-2006			
Title of Invention:	Positive-type resist composition for liquid immersion lithography and method for forming resist pattern			
First Named Inventor/Applicant Name:	Keita Ishiduka			
Filer:	Nichole Elizabeth Martiak/Kathleen Goodhand			
Attorney Docket Number:	1608-7 PCT/US			
Filed as Large Entity				
U.S. National Stage under 35 USC 371 Filing Fees				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Claims in excess of 20	1615	2	52	104
Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
Post-Allowance-and-Post-Issuance:				
Extension-of-Time:				

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Request for continued examination	1801	1	810	810
Total in USD (\$)				914